

Electro-Optic Bunch Profile Monitor for the CERN-CTF3 probe beam


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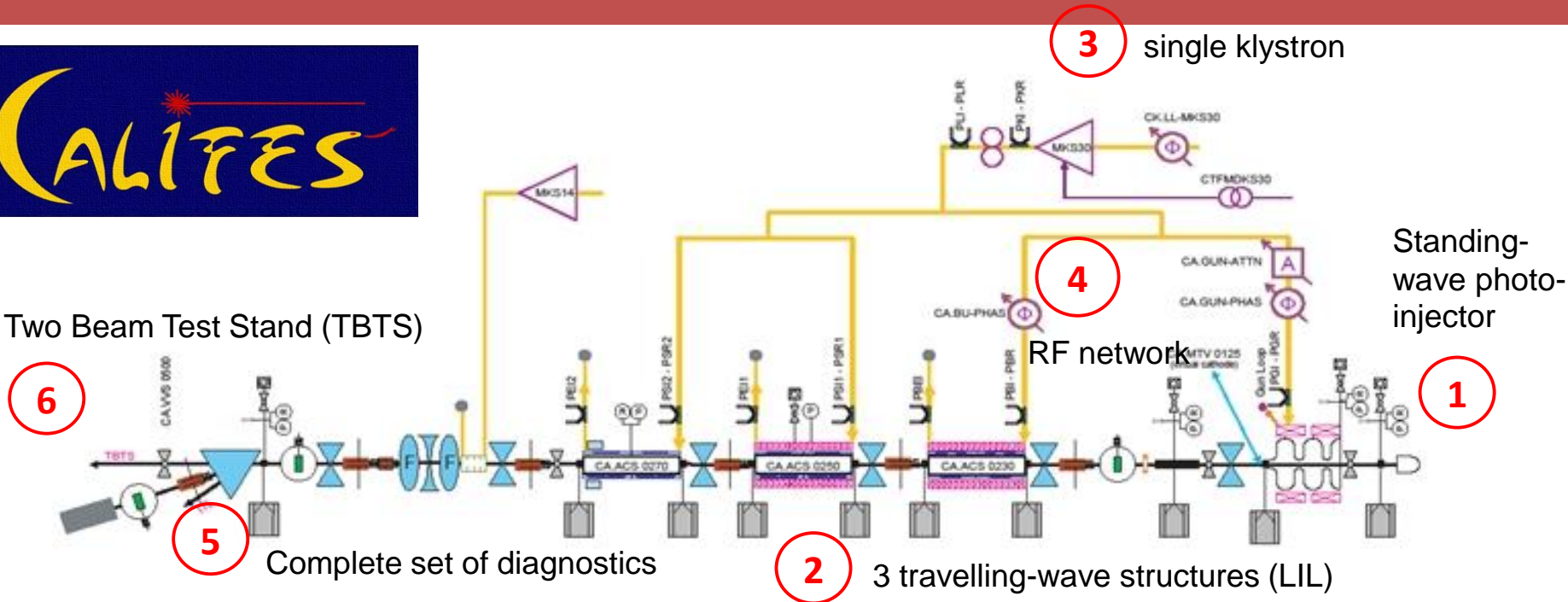
Outline

- 
- Introduction for CALIFES**
 - EOSD principle and Simulation**
 - EO bunch profile monitor system**
 - Resolution**
 - Summary**

Introduction ---- CALIFES



to Two Beam Test Stand (TBTS)



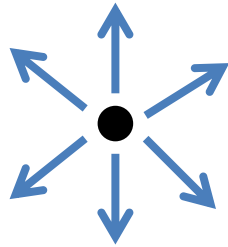
Energy	200 MeV
Train duration max.	140ns
Train rep. rate	5 Hz
Bunch length	8-10 ps (1.4 ps)
Bunch rep. rate	1.5 GHz
Bunch charge	0.1–0.05nC (0.6 nC)

Existing bunch profile monitor:

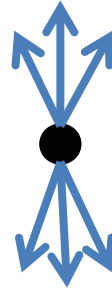
1. Deflecting cavity (bunch head downward, tail upward)
2. Bunch length measurement with an acceleration structure (bunch head decelerated, tail accelerated)

Coulomb field of e-bunch

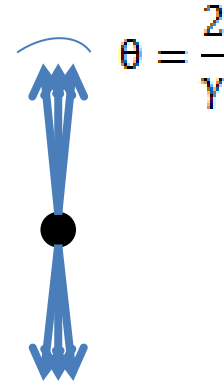
Coulomb field temporal profile



$\beta=0$



$\beta=0.9$



$\beta=0.9999$

$$E_{e0}(r_0, t) = \frac{e_0 \gamma}{4\pi \epsilon_0} \cdot \frac{r_0}{(r_0^2 + \gamma^2 v_e^2 (t - t_0)^2)^{3/2}}$$

Coulomb field of one electron

- High energy , Coulomb field temporal profile is approximately the bunch temporal profile

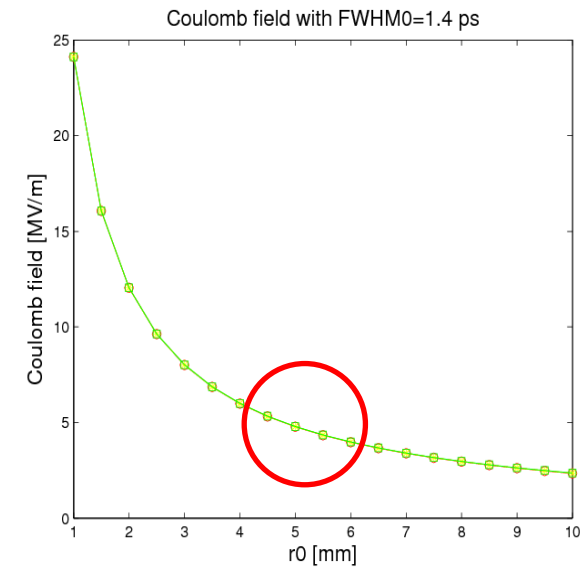
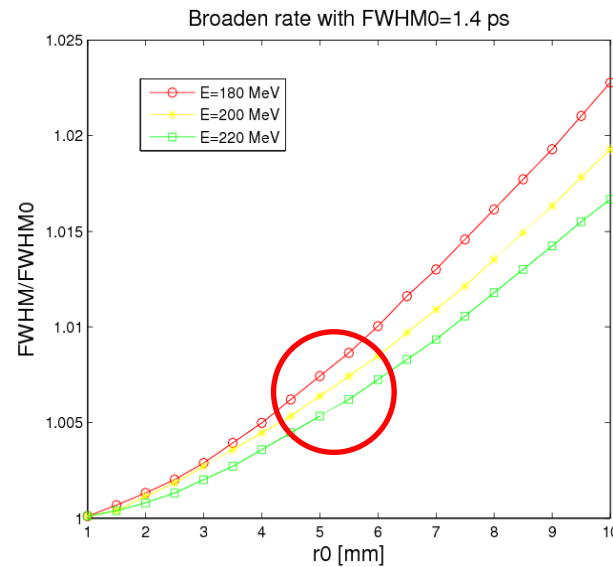
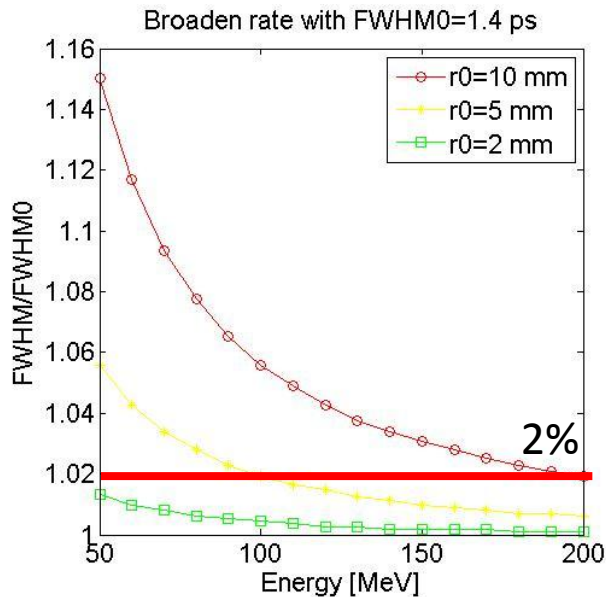
- Broadening of profile: $\Delta t \sim \frac{2r}{\gamma}$

Simulation: Coulomb field of e-bunch

Coulomb field temporal profile and broadening

$$E_{Colm} = E_{e0} * \rho$$

- Radial offset from single electron E_{e0}
- Electrons' density distribution within one bunch ρ
- Convolution



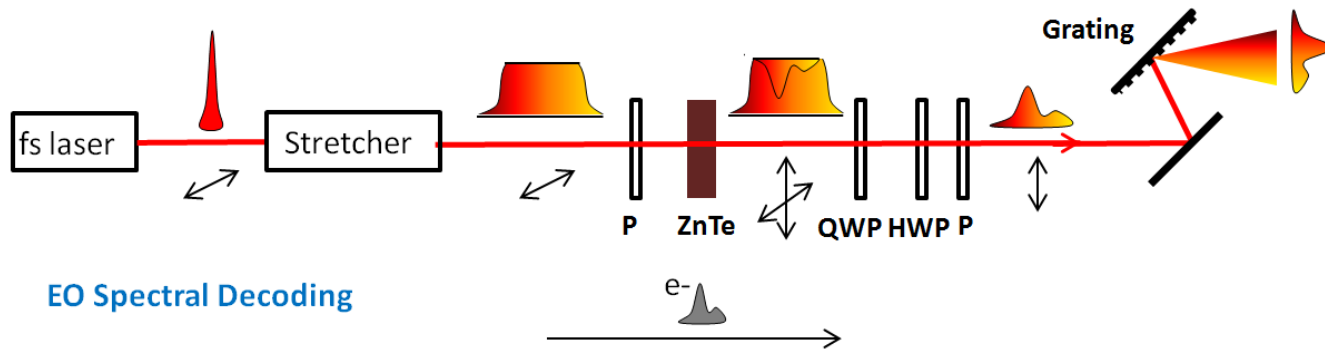
For high energy beam (200 MeV):
Broadening rate < 2% @ 10 mm

r0: the distance far away from e-bunch

Damage to crystal ← Closer → Further → Crystal survives, low Coulomb field

Simulation: EOSD

Electro-Optical Spectral Decoding:



EO bunch profile measurements:

- EO spectral decoding
- EO temporal decoding
- EO spatial encoding
- EO up conversion

- Linear chirped optical pulse
- Polarization variation caused by Coulomb field—laser nonlinear effect
- Polarization \rightarrow Intensity, by two crossed polarizers
- $I(\lambda) \leftrightarrow I(t)$

$$E_{out} = \begin{pmatrix} 0 & 1 \end{pmatrix} R(\varphi) M_{hw} R(-\varphi) R(\alpha) M_{qw} R(-\alpha) R(\theta) M_{EO} R(-\theta) \begin{pmatrix} E_{opt}^{chirp}(f) \\ 0 \end{pmatrix}$$

$R(\theta)$ ----- rotation matrix

M_{qw} ----- Jones matrix for quarter waveplate

M_{hw} ----- Jones matrix for half waveplate

Simulation: EO phase mismatching

EO effect:

Frequency mixing

induce

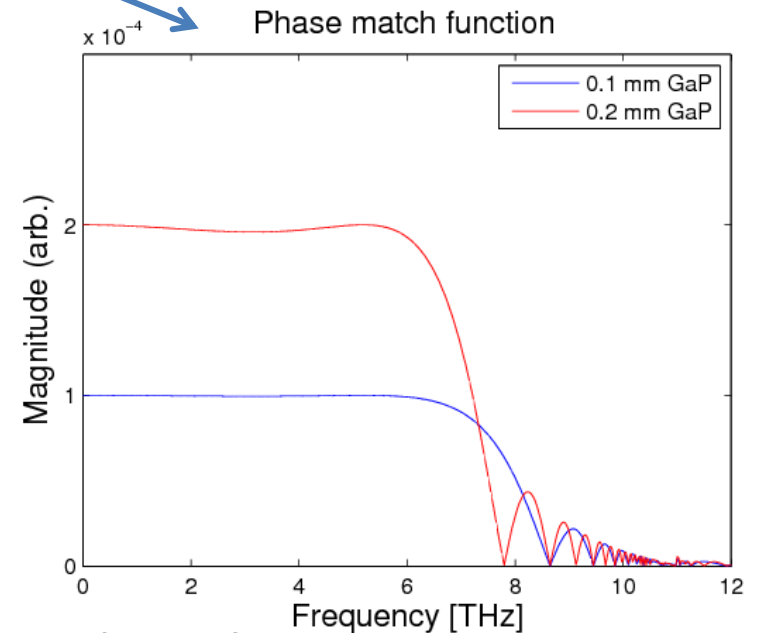
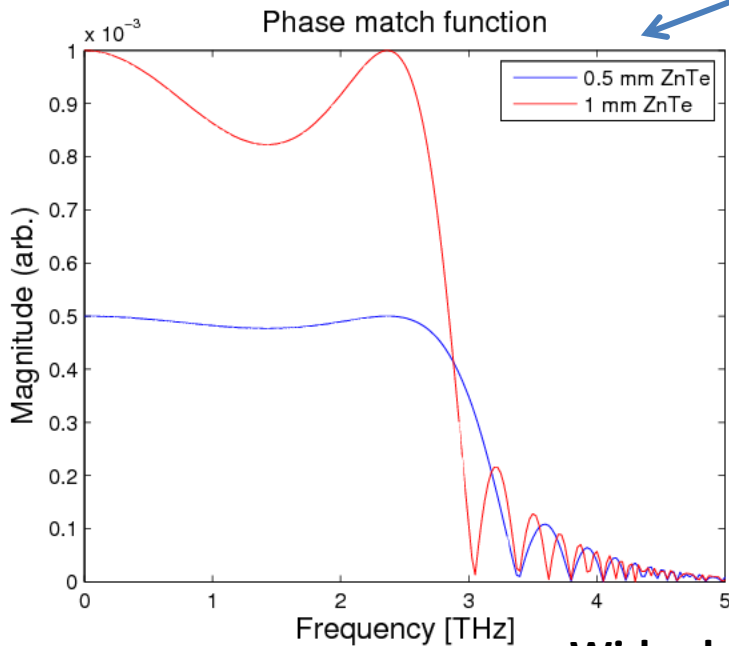


Polarization variation

$$\tilde{E}_{sum}(z, \omega) = \frac{i\omega^2}{2c^2 k_{opt}^R(\omega)} \exp [ik_{opt}(\omega)z] \times \int_{-\infty}^{+\infty} d\Omega \left\{ \chi_{eff}^{(2)}(\omega, \Omega) \left[\frac{\exp(i\Delta k(\omega, \Omega)z) - 1}{i\Delta k(\omega, \Omega)} \right] \times \tilde{E}_{THz}(0, \Omega) \tilde{E}_{opt}(0, \omega - \Omega) \right\}$$

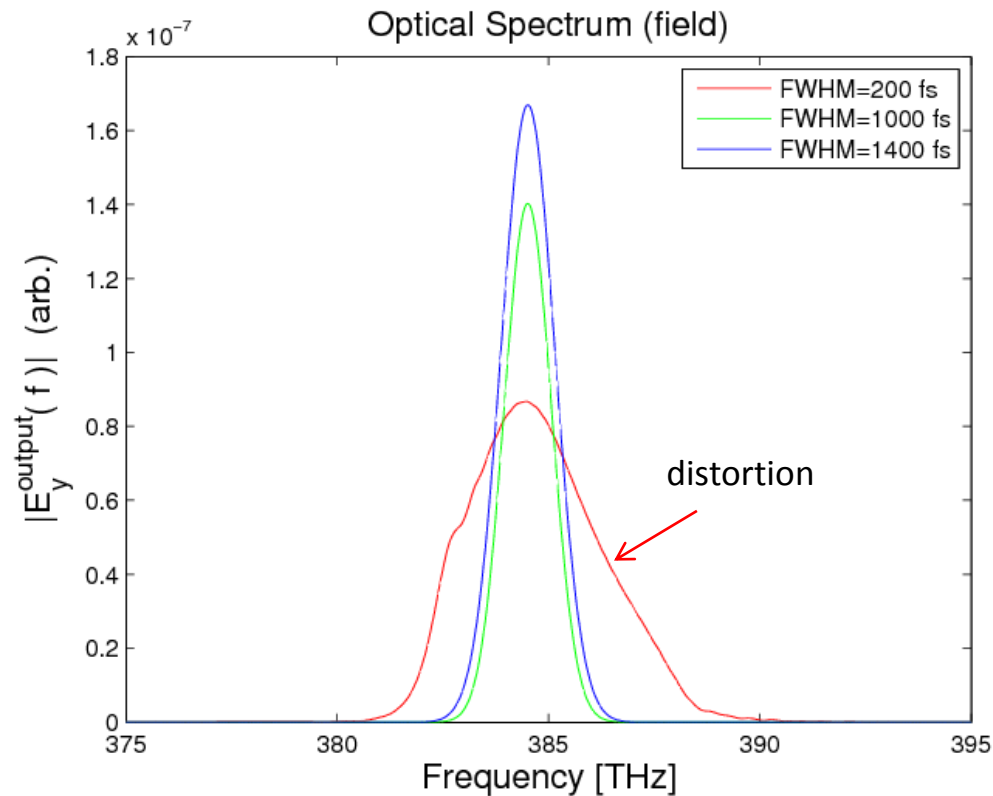
Coulomb field

Laser



Wider bandwidth, better resolution !

Simulation: EOSD results and limitation



Other parameters:

Laser wavelength: 780nm

Laser pulse energy: 1.5nJ

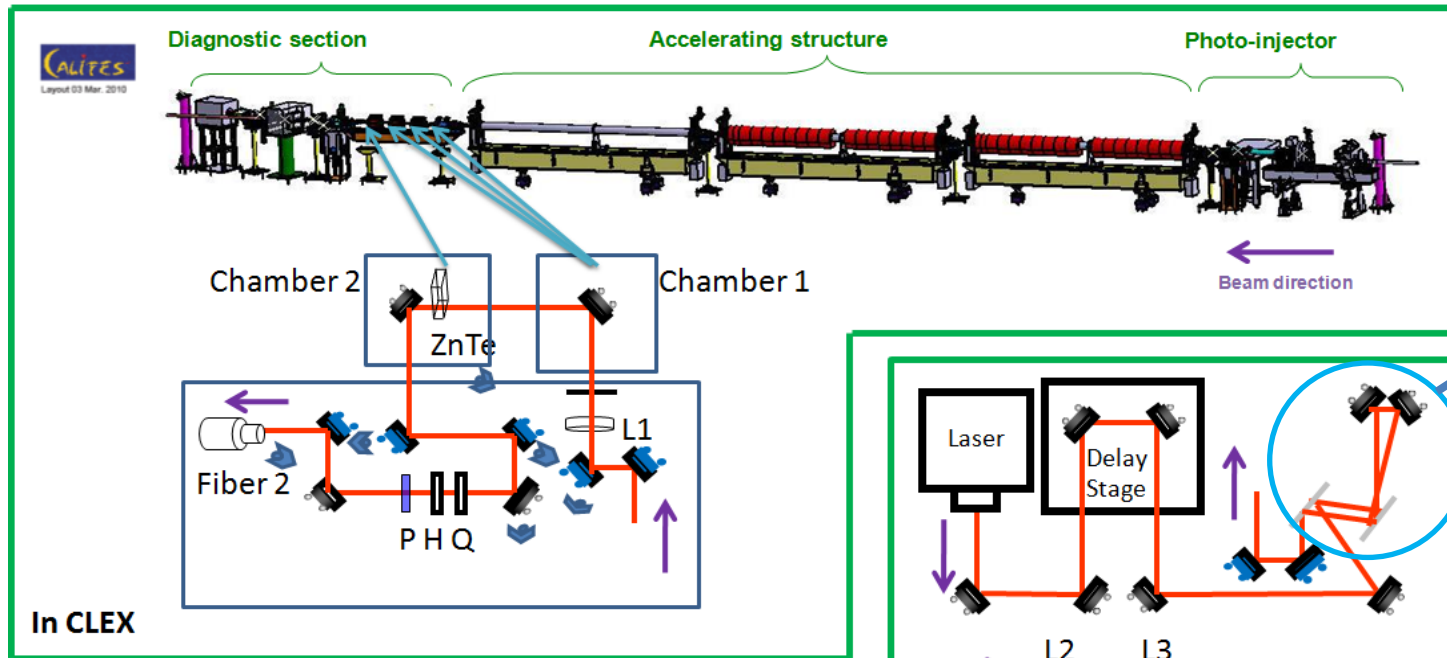
Pulse duration: 150fs

Crystal thickness: 1mm

Distance: 5mm

Short bunch----fast temporal modulation---- spectral content
---- $t \sim \lambda$ mapping

EO monitor Design for CALIFES



Stretcher:
 ● SF11 glass
 ● 100fs----3.24ps

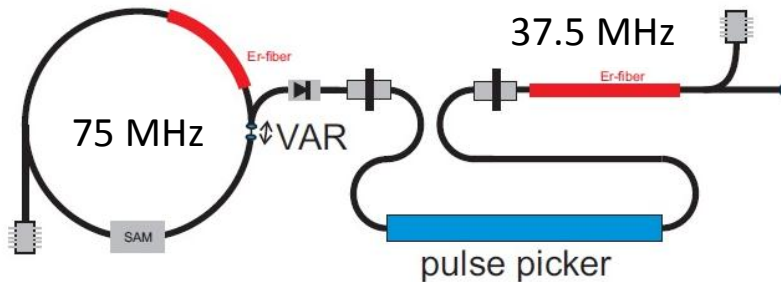


In CLEX		In Lab	
10 Motors	7 plane mirrors	1 Laser	10 plane mirrors
3 Rotate motors	2 polarizers	1 InGaAs Camera	3 gratings
6 Pinhole cameras	3 wave plates	1 motor stage	3 lens
	1 lens	4 Motors	1 fiber head
	1 fiber head		
	2 photodiodes		

Scheme

Laser system

Laser system

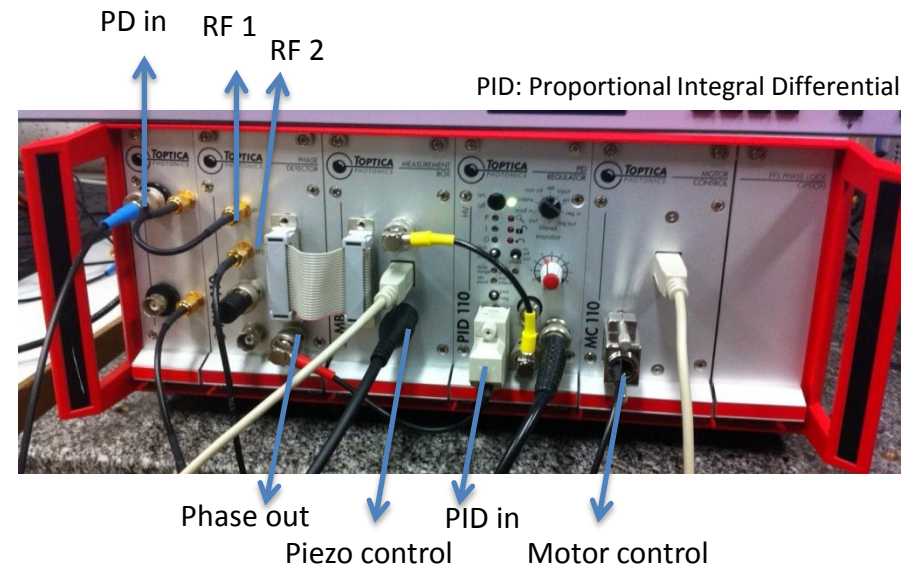


Custom Erbium fiber laser with pulse picker

Fundamental wavelength	1560 nm
Laser output power	> 350 mW
Pulse width	< 120 fs
Repetition rate	37.482 MHz
Second-harmonic wavelength	780 nm
Laser output power	> 120 mW
Pulse width	< 120 fs
Beam size ($1/e^2$)	Typ. \varnothing 1.2 mm (780 nm) Typ. \varnothing 3.5 mm (1560 nm)
Beam divergence	< 1 mrad (780 nm) < 2 mrad (1560 nm)

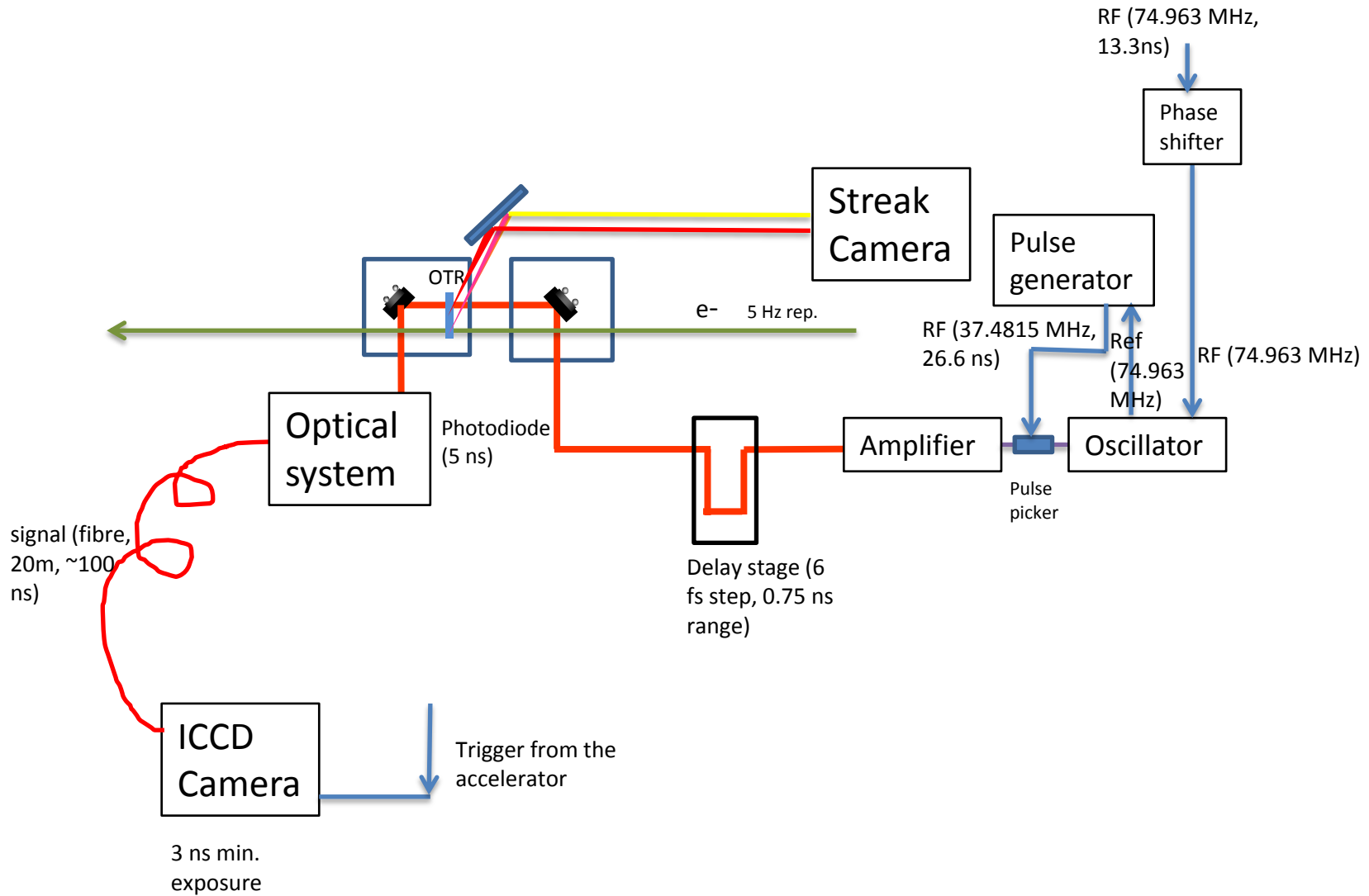


Laser head and controller



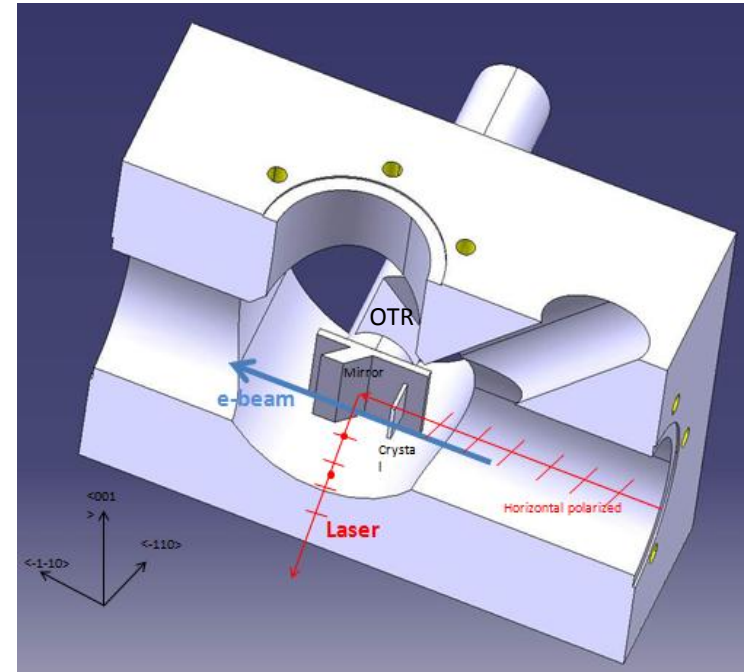
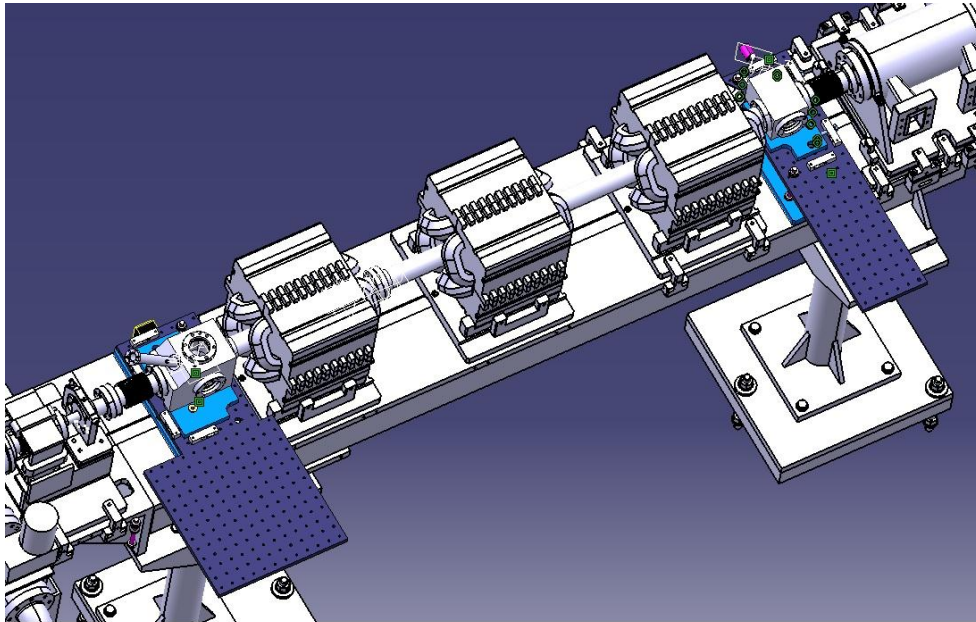
Synchronization box

Timing and synchronization scheme

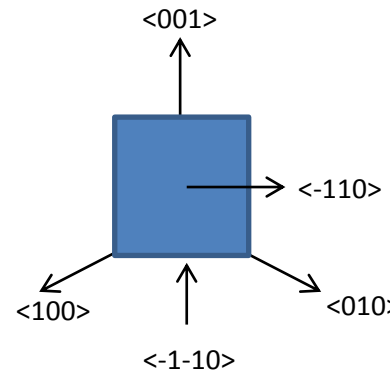


EO monitor Design for CALIFES

Chamber design

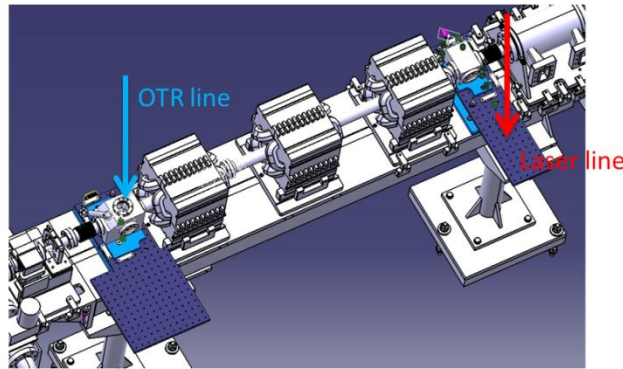
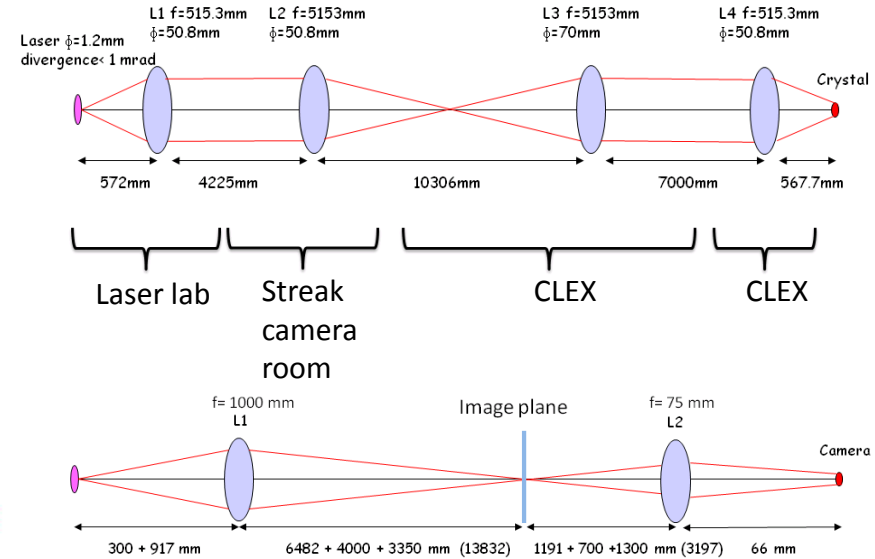
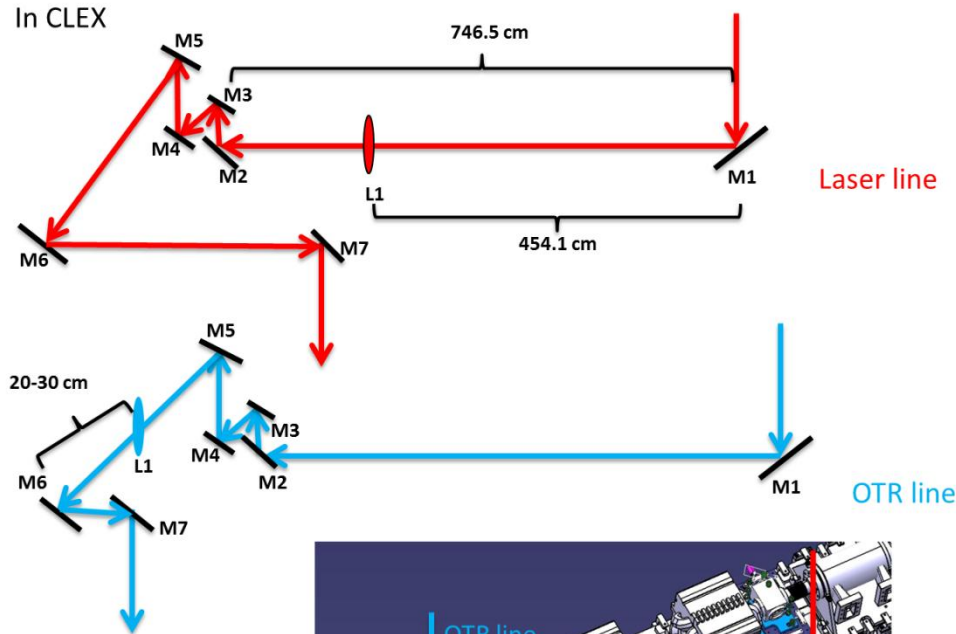


First chamber includes a mirror
The second chamber includes a mirror, a crystal and a OTR screen



Crystal orientation

Laser/OTR Transfer Line



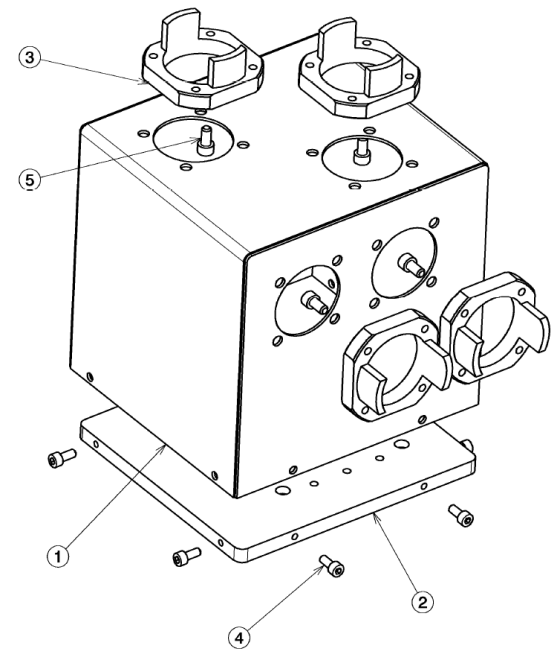
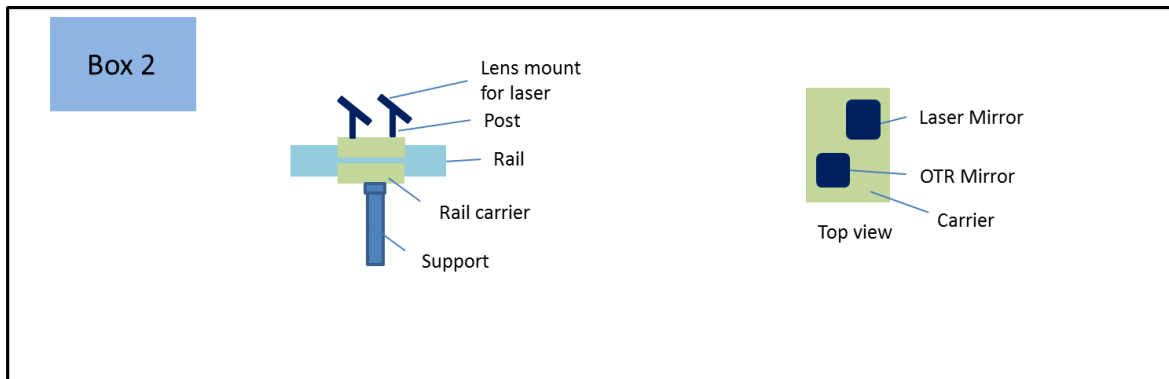
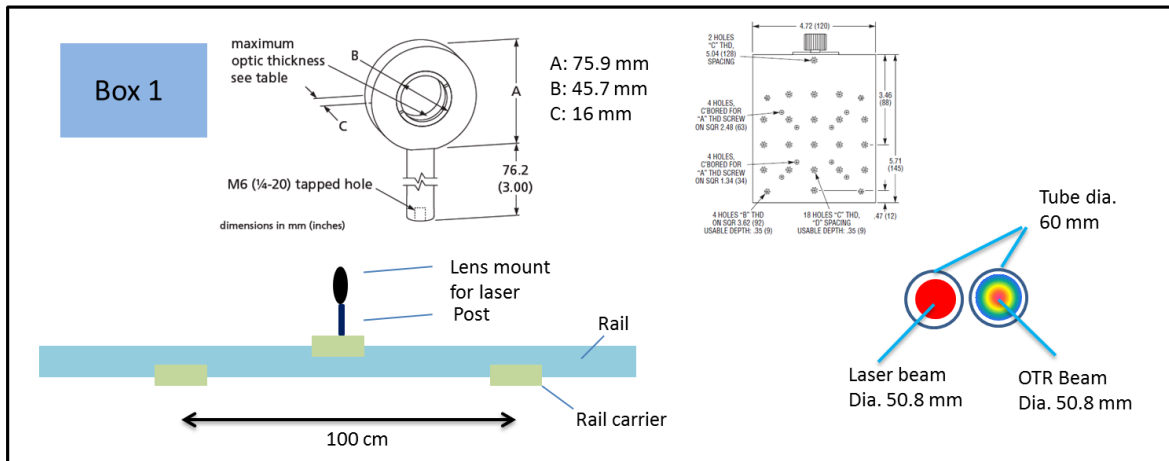
We transfer the 780nm fs laser from our laser lab (building 2010-1-002) to CLEX, and transfer the OTR photons from CLEX to our lab.

Laser/OTR Transfer Line 2

Installation:

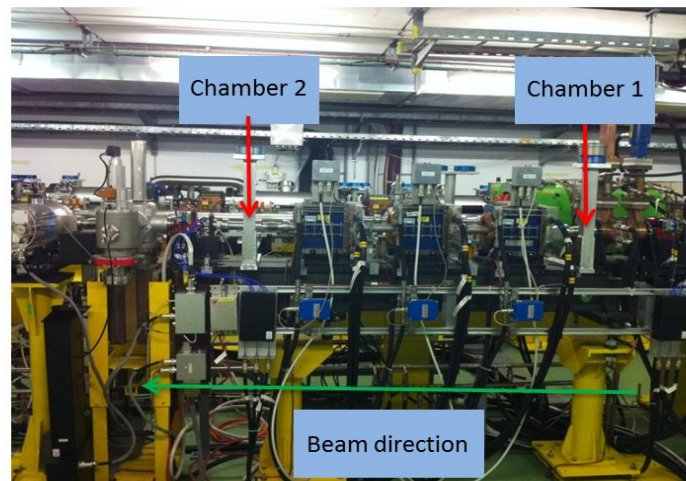
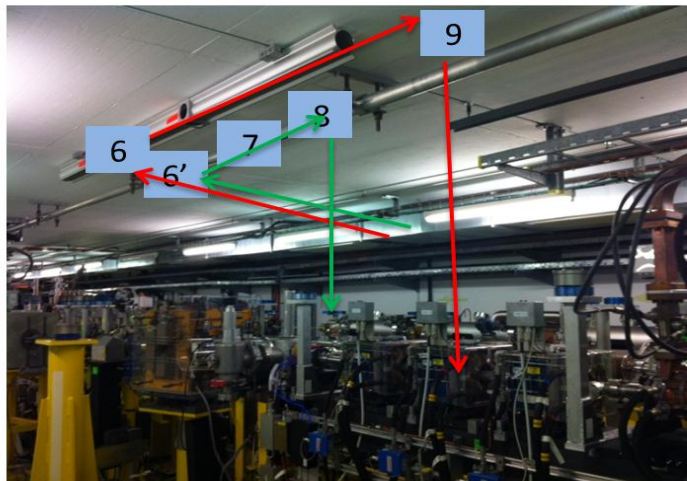
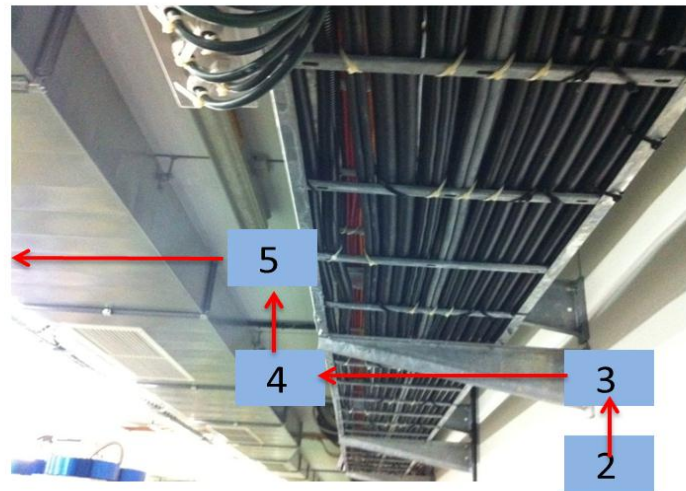
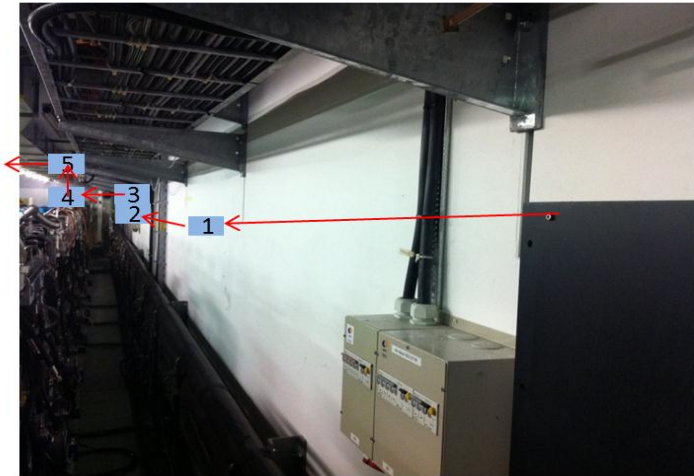
Take the box1 and box2 for example

Box details:



Mirror/lens cover box

Laser/OTR Transfer Line 3



Expected Resolution

1. Distance between crystal and e-beam

$$\Delta t \sim \frac{2r}{\gamma} \sim 10 \text{ fs} \quad \text{at } r=5 \text{ mm}$$

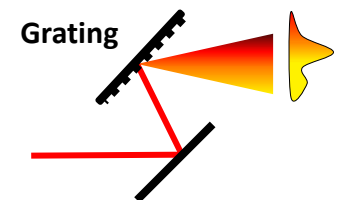
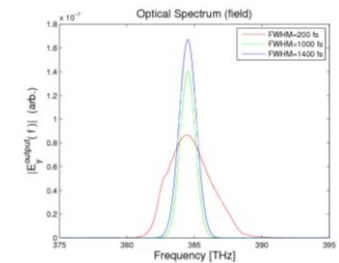
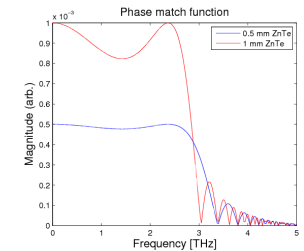
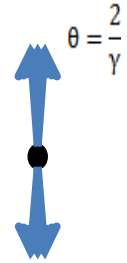
2. The frequency response of crystal (material and thickness)

$$\text{for 1 mm ZnTe: } \sim 333 \text{ fs} \quad \sim 1/(3\text{THz})$$

3. EOSD limitation (Laser pulse duration and chirped duration)




$$\tau_{\text{lim}} = \sqrt{\tau_0^{\text{FWHM}} \tau_c^{\text{FWHM}}} \sim 550 \text{ fs} \quad (100 \text{ fs} \rightarrow 3 \text{ ps})$$

4. Resolution of spectrometer and CCD $\sim 40 \text{ fs}$ (512 pixels)





Summary & Outlook

Summary:

-  EO technique is a non-destructive testing technique, and has the feasibility in fs resolution.
-  System simulation, designs of laser system, transfer line, chambers, detection system and timing and synchronization have done.
-  Based on numerical simulation, the resolution of this system is expected to be sub-picosecond.

Outlook:

-  The system waiting for being installed during the winter shut down. First measurement in the beginning of next year.
-  Resolution improvement study

This research project has been supported by a Marie Curie Early Initial Training Network Fellowship of the European Community's Seventh Framework Programme under contract number (PITN-GA-2008-215080-DITANET)

Thank You !

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